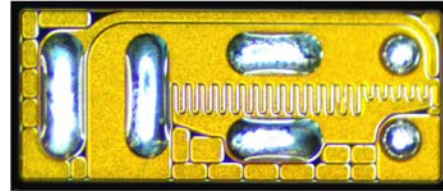


# EPC8008 – Enhancement Mode Power Transistor

## Preliminary Specification Sheet

### Features:

- $V_{DS}$ , 40V
- $R_{DS(on)}$ , 325 m $\Omega$
- $I_D$ , 2.7 A
- Optimized eGaN<sup>®</sup> FET for high frequency applications
- Pb-Free (RoHS Compliant), Halogen Free



EPC8008 eGaN FETs are supplied only in passivated die form with solder bars

### Applications:

- Ultra high speed DC-DC conversion
- RF Envelope Tracking
- Wireless Power Transfer
- Game console and industrial movement sensing (LiDAR)

### MAXIMUM RATINGS

Parameter	Value
Maximum Drain – Source Voltage	40 V
Gate – Source Maximum Voltage Range	$-5\text{ V} < V_{GS} < 6\text{ V}$
Continuous Drain Current, 25 °C, $\theta_{JA} = 33$	2.7 A
Maximum Pulsed Drain Current, 25 °C, $T_{pulse} = 300\ \mu\text{s}$	2.9 A
Operating Temperature Range	$-40\text{ °C} < T_J < 150\text{ °C}$

### STATIC CHARACTERISTICS

Parameter	Conditions	Value
Maximum Drain – Source Leakage	$V_{DS} = 32\text{ V}, V_{GS} = 0\text{ V}$	0.1 mA
Maximum $R_{DS(ON)}$	$V_{GS} = 5\text{ V}, I_D = 0.5\text{ A}$	325 m $\Omega$
Gate – Source Threshold Voltage	$V_{DS} = V_{GS}, I_D = 0.25\text{ mA}$	$0.7\text{ V} < V_{GS(TH)} < 2.5\text{ V}$
Gate – Source Maximum Positive Leakage	$V_{GS} = 5\text{ V}$	0.5 mA
Gate – Source Maximum Negative Leakage	$V_{GS} = -5\text{ V}$	-0.1 mA

$T_J = 25\text{ °C}$  unless otherwise stated

Specifications are with Substrate shorted to Source where applicable

# EPC8008 – Enhancement Mode Power Transistor

## Preliminary Specification Sheet



### DYNAMIC CHARACTERISTICS

Parameter	Conditions	Typical Value
$C_{ISS}$ (Input Capacitance)	$V_{DS} = 20\text{ V}; V_{GS} = 0\text{ V}$	25 pF
$C_{OSS}$ (Output Capacitance)		8 pF
$C_{RSS}$ (Reverse Transfer Capacitance)		0.2 pF
$Q_G$ (Total Gate Charge)	$V_{DS} = 20\text{ V}; I_D = 1\text{ A}$	177 pC
$Q_{GD}$ (Gate to Drain Charge)		12 pC
$Q_{GS}$ (Gate to Source Charge)		67 pC
$Q_{OSS}$ (Output Charge)	$V_{DS} = 20\text{ V}; V_{GS} = 0\text{ V}$	211 pC
$Q_{RR}$ (Source-Drain Recovery Charge)		0 pC

$T_J = 25\text{ }^\circ\text{C}$  unless otherwise stated

Specifications are with Substrate shorted to Source where applicable

### THERMAL CHARACTERISTICS

		TYP	
$R_{\theta JC}$	Thermal Resistance, Junction to Case	6.7	$^\circ\text{C/W}$
$R_{\theta JB}$	Thermal Resistance, Junction to Board	33	$^\circ\text{C/W}$
$R_{\theta JA}$	Thermal Resistance, Junction to Ambient (Note 1)	82	$^\circ\text{C/W}$

Note 1:  $R_{\theta JA}$  is determined with the device mounted on one square inch of copper pad, single layer 2 oz copper on FR4 board.

See [http://epc-co.com/epc/documents/product-training/Appnote\\_Thermal\\_Performance\\_of\\_eGaN\\_FETs.pdf](http://epc-co.com/epc/documents/product-training/Appnote_Thermal_Performance_of_eGaN_FETs.pdf) for details.

# EPC8008 – Enhancement Mode Power Transistor

## Preliminary Specification Sheet

Figure 1:

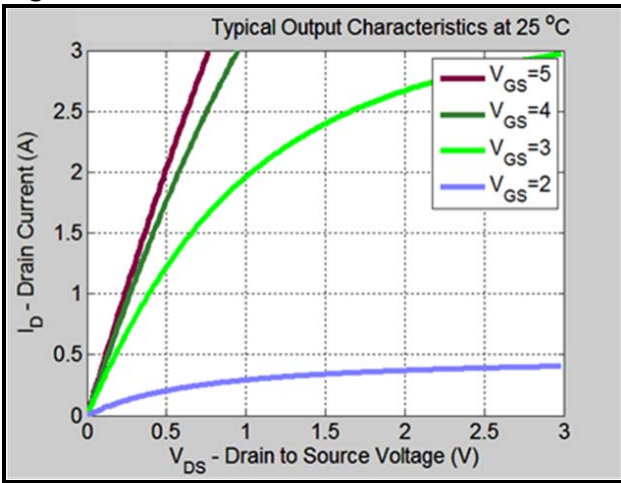


Figure 2:

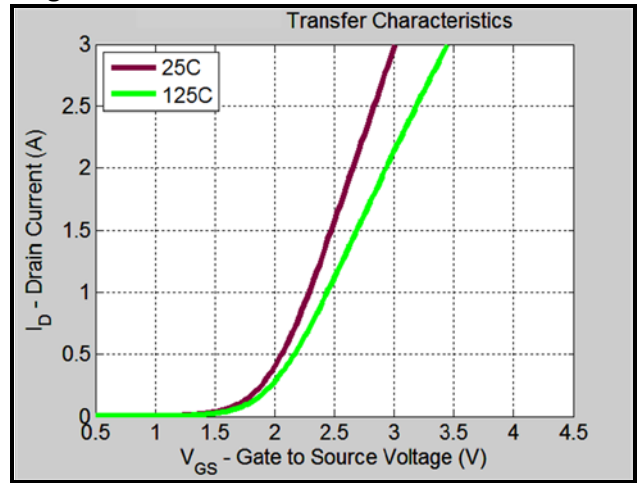


Figure 3:

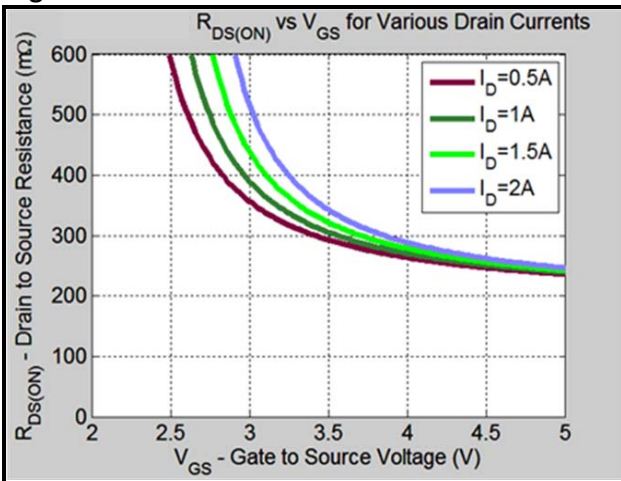


Figure 4:

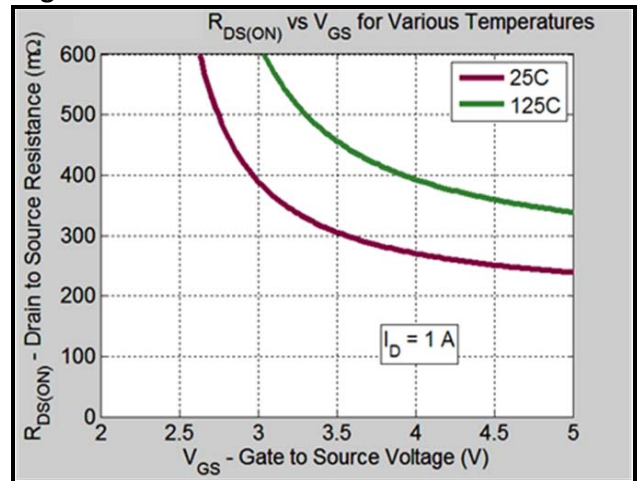
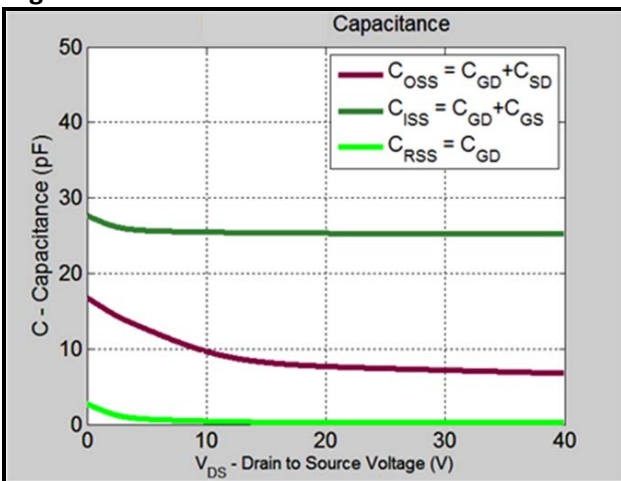
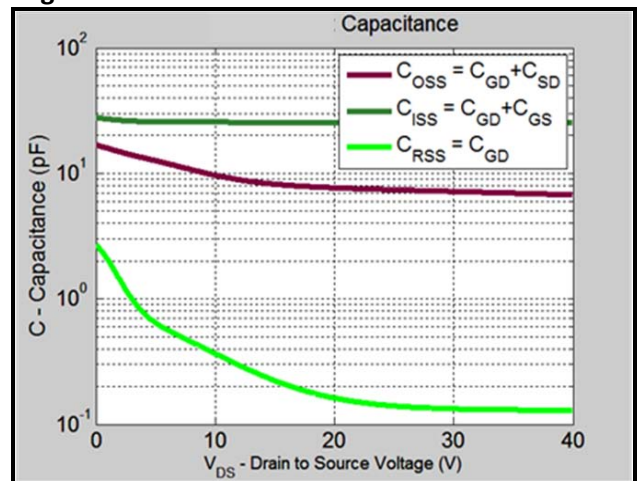


Figure 5a:



Linear Scale

Figure 5b:



Log Scale

# EPC8008 – Enhancement Mode Power Transistor Preliminary Specification Sheet



Figure 6:

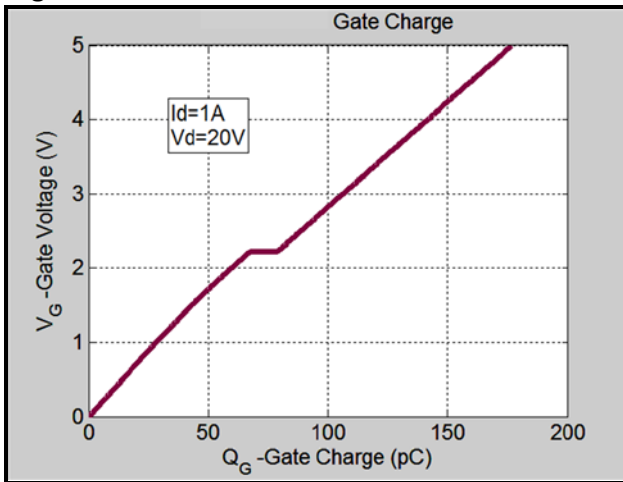


Figure 7:

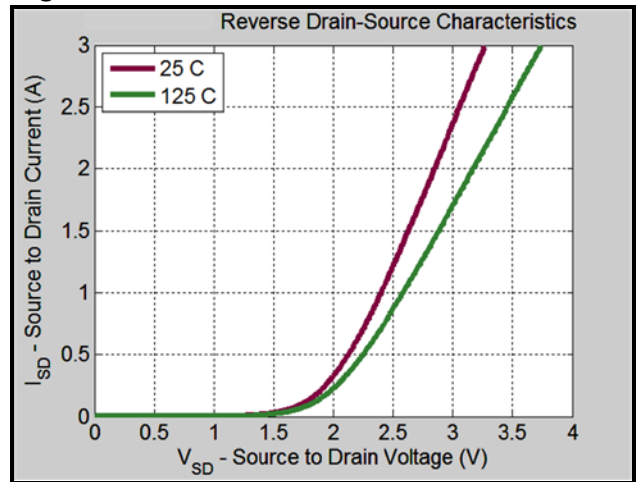


Figure 8:

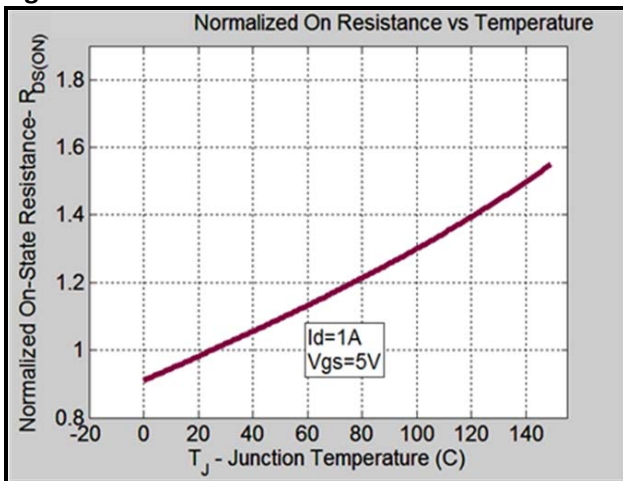
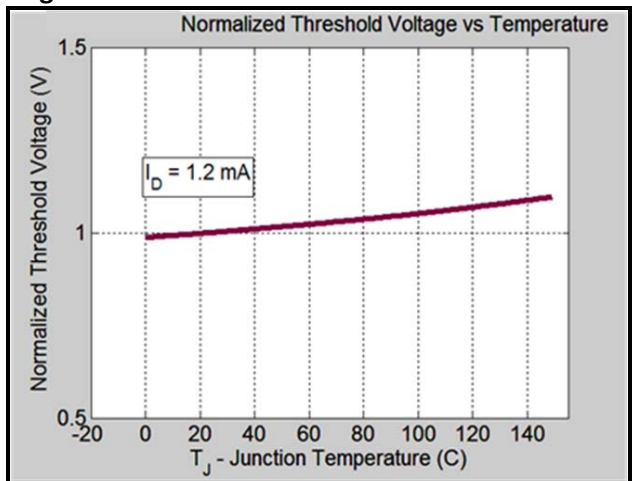


Figure 9:



All measurements were done with substrate shorted to source

# EPC8008 – Enhancement Mode Power Transistor Preliminary Specification Sheet

## S-PARAMETER CHARACTERISTICS

$V_{GSQ} = 1.36\text{ V}$ ,  $V_{DSQ} = 20\text{ V}$ ,  $I_{DQ} = 0.20\text{ A}$

Pulsed measurement, Heat-Sink Installed,  $Z_0 = 50\ \Omega$

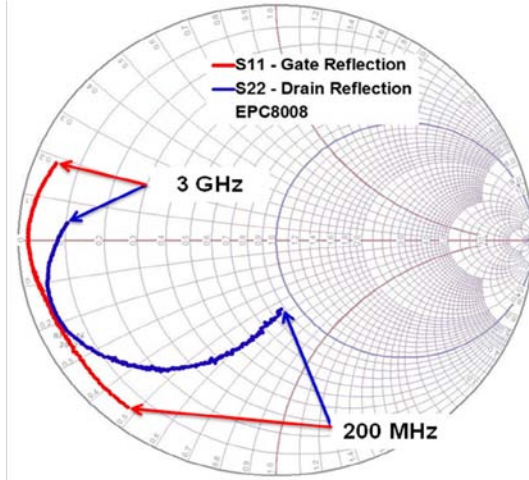


Figure 10: Smith Chart

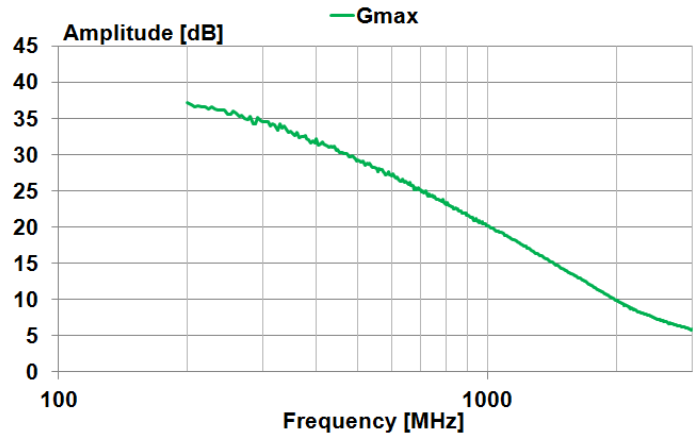


Figure 11: Gain Chart

Frequency [MHz]	Gate ( $Z_{GS}$ ) [ $\Omega$ ]	Drain ( $Z_{DS}$ ) [ $\Omega$ ]
200	$2.85 - j23.62$	$43.87 - j27.69$
500	$2.15 - j9.27$	$18.81 - j28.70$
1000	$1.25 - j3.13$	$5.58 - j16.48$
1200	$1.10 - j1.66$	$3.68 - j13.31$
1500	$0.91 + j0.27$	$2.48 - j9.04$
2000	$1.09 + j3.20$	$2.71 - j3.84$
2400	$1.35 + j5.39$	$3.67 - j0.93$
3000	$2.19 + j9.37$	$5.10 + j2.36$

Table 1: S-Parameter Table

Download S-parameter files at [www.epc-co.com](http://www.epc-co.com)

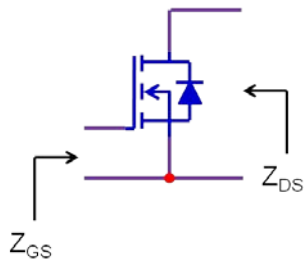


Figure 12: Device Reflection

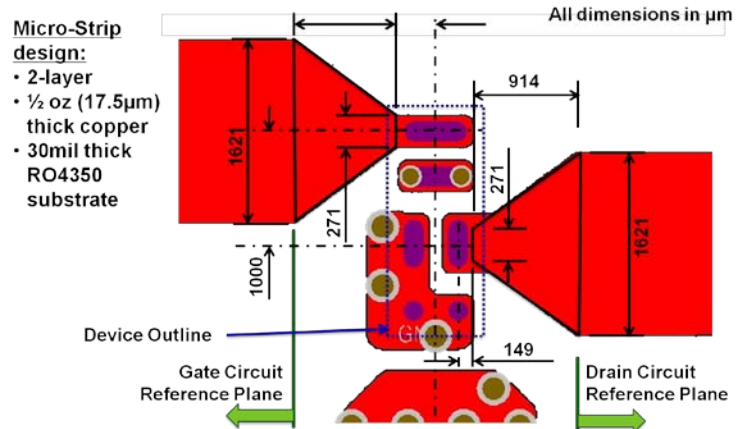
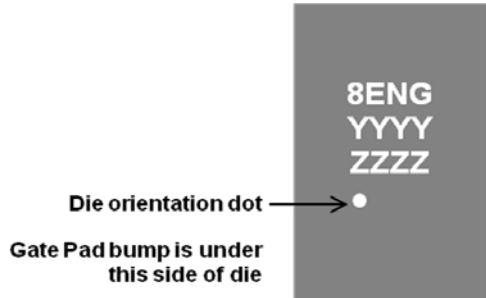


Figure 13: Taper and Reference Plane details – Device Connection

# EPC8008 – Enhancement Mode Power Transistor

## Preliminary Specification Sheet

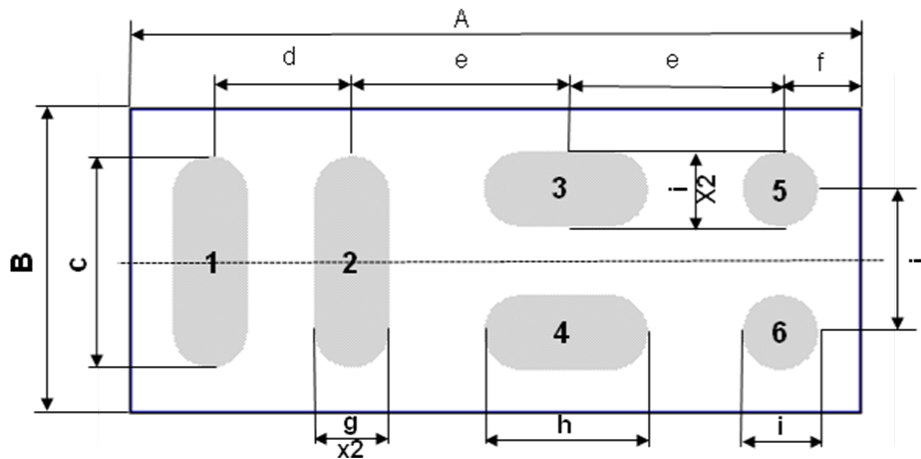
### DIE MARKINGS



Part Number	Laser Marking		
	Part # Marking Line 1	Lot_Date Code Marking Line 2	Lot_Date Code Marking Line 3
EPC8008	8ENG	YYYY	ZZZZ

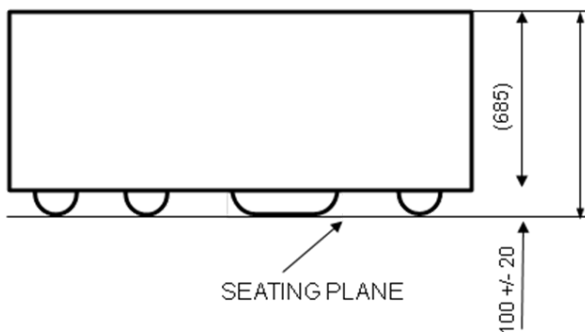
### DIE OUTLINE

#### Solder Bar View



DIM	MICROMETERS		
	MIN	Nominal	MAX
A	2020	2050	2080
B	820	850	880
c	555	580	605
d	400	400	400
e	600	600	600
f	200	225	250
g	175	200	225
h	425	450	475
i	175	200	225
j	400	400	400

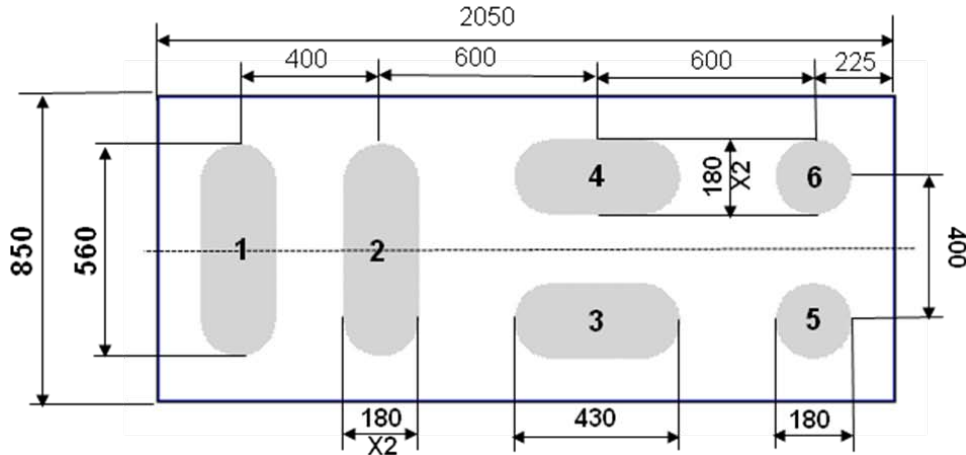
#### Side View



# EPC8008 – Enhancement Mode Power Transistor Preliminary Specification Sheet

## RECOMMENDED LAND PATTERN

(units in  $\mu\text{m}$ )



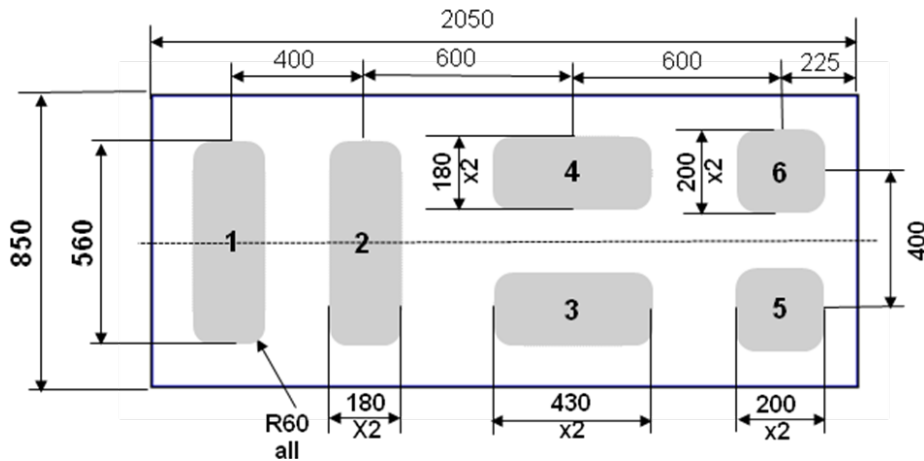
- Pad no. 1 is Gate
- Pad no. 2 is Source Return for Gate Driver
- Pad no. 3 and 5 are Source
- Pad no. 4 is Drain
- Pad no. 6 is Substrate

Land pattern is solder mask defined

Solder mask opening is 10  $\mu\text{m}$  smaller per side than bump

## RECOMMENDED STENCIL

(units in  $\mu\text{m}$ )



- Pad no. 1 is Gate
- Pad no. 2 is Source Return for Gate Driver
- Pad no. 3 and 5 are Source
- Pad no. 4 is Drain
- Pad no. 6 is Substrate

Recommended stencil should be 4mil (100 $\mu\text{m}$ ) thick, must be laser cut, openings per drawing.

**Note that openings for pads 5 & 6 are larger than solder mask opening.**

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 U.S. Patents 8,350,294; 8,404,508; 8,431,960; 8,436,398

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